

# Temperature-Aware and Low-Power Design and Synthesis of Integrated Circuits and Systems

Robert P. Dick

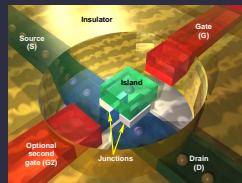
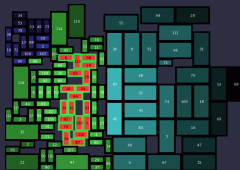
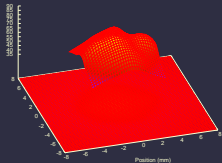
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Temperature (°C)



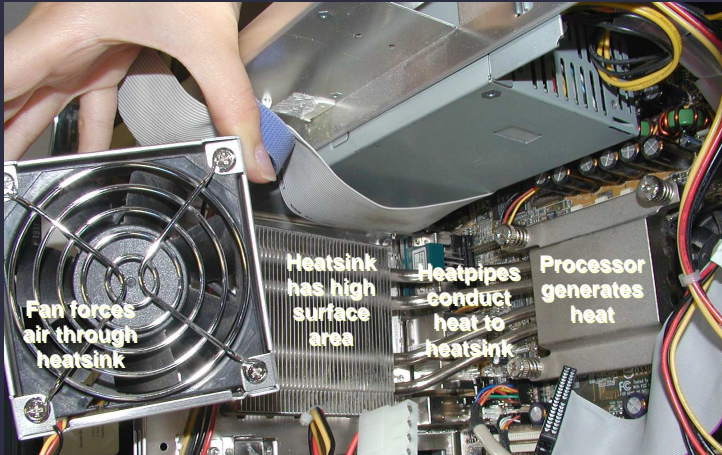
# Outline

1. Introduction
2. Forced air and heatsinks
3. Alternative technologies
4. Solid State

# Introduction

- Cooling fundamentals
- Multiple cooling methods
  - Combinations often used in real applications

# Multiple modes common in real applications



# Conduction

$$P = A\kappa \cdot \Delta T/d$$

- $P$ : Power in W
- $A$ : Area
- $\kappa$ : Thermal conductivity
- $\Delta T$ : Difference in temperature
- $d$ : Depth

# Radiative cooling

$$P = Ae\sigma T^4 - Ae\sigma T_A^4$$

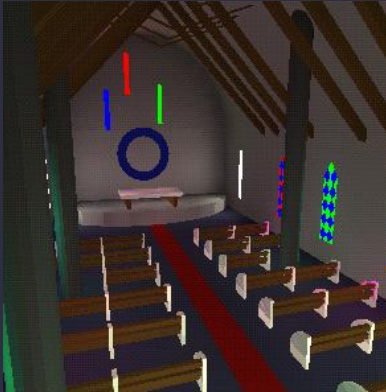
- $P$ : Power in W
- $A$ : Surface area
- $e$ : Emissivity of surface [0:1]
  - 0.3 for Cu, 0 for rough black surface
- $\sigma$ : Stefan-Boltzmann constant =  $5.67 \times 10^{-8} \text{ W}/(\text{m}^2 \text{ K})$
- $T$ : Temperature
- $T_A$ : Ambient temperature
- Why does a thermos have mirrored walls?

# Radiative interaction

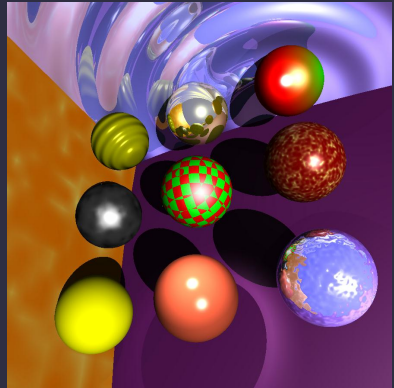
$$k = \frac{A \cos \theta}{4\pi r^2}$$

- $k$ : Patch interaction coefficient
- $A$ : Patch area
- $\theta$ : Angle between patches
- $r$ : Distance between patches

# Other uses of radiation



Radiosity



Ray tracing



# Convection

Convection:

$$P = 2hA(T_S - T_F)$$

$$h \approx k_1(T_S - T_F)^{1/4}$$

Therefore,

$$I \propto (T_S - T_F)^{5/4}$$

- $P$ : Power in W
- $h$ : Heat transfer coefficient
- $k_1$ : Constant for film coefficient and film conductance (0.0021 W/(m<sup>2</sup> K))
- $A$ : Area of one side of plate
- $T_S$  and  $T_F$ : Solid and fluid temperatures

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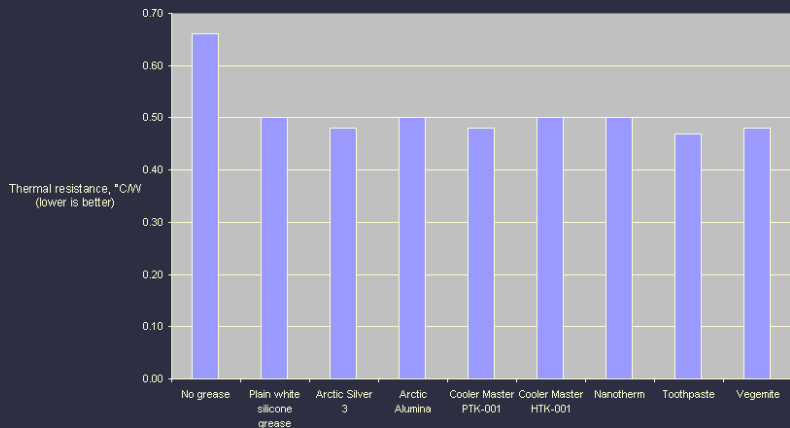
# Forced air heatsink

## How to improve?

- Increase fluid flow rate, decreasing surface film thickness
- Or increase film conductance
  - Increases  $k_1$
- Increase surface area
- Increase temperature difference (?)
- Increase conductance to heatsink

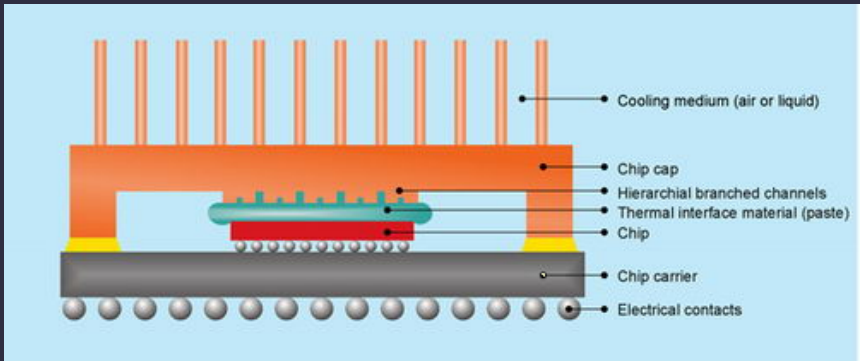
# Thermal compounds

## Thermal compound performance comparison



Credit to Dan's Data and Vegemite.

## Heatsink attachment



- IBM proposes cutting tree-structure trenches in chip cap
- Thinner interface material, less pressure, few details

## Heatsink attachment

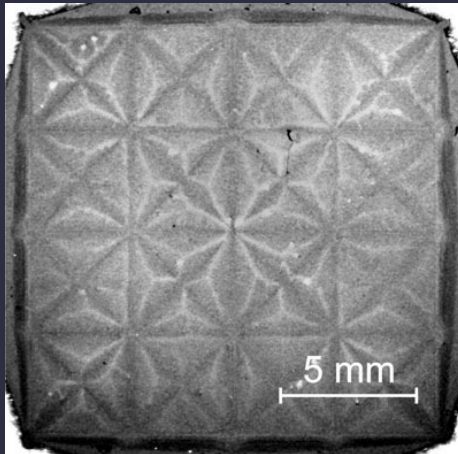


Image credit to IBM.

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# Ion pump cooling

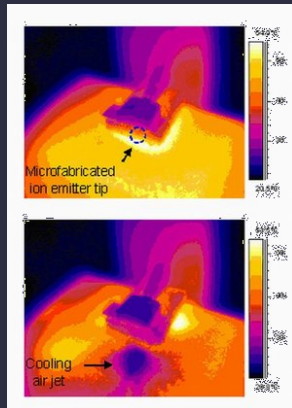


Image credit to N. Jewell-Larsen.



# Ion pump operation

- High-voltage positive electrode ionizes air
- Ions travel to negative electrode (chip)
- Air pulled along
- Cooled a few  $\text{mm}^2$  by  $25^\circ\text{C}$  this way
- Claiming  $180\text{ W}/(\text{mm}^2\text{ K})$  at 4.5 kV,  $2\text{ mm}^2$

# Liquid cooling

- Specific heat capacity of water  $4\times$  air
- Thermal conductivity  $25\times$  air
- Passive: Vat of oil
- Active: Recirculating pump
  - Where does heat go?
- Microchannel

# Microchannel

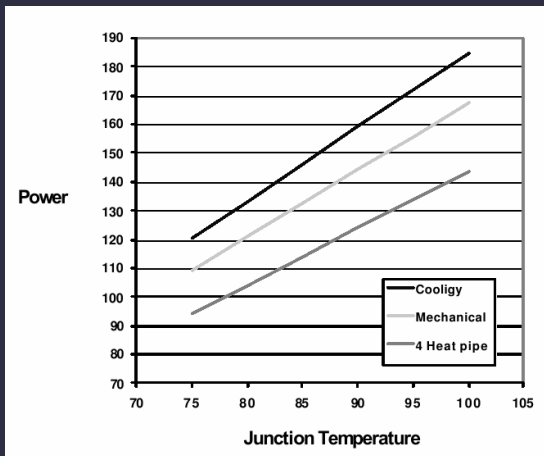
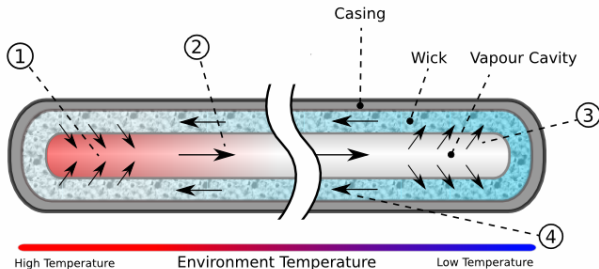


Image credit to Cooligy.

# Phase change

- Abrupt change in heat capacity
- Result in transfer in large amount of energy
  - Rate bound results in mixed state
- Latent heat: Amount of energy released or absorbed during evaporation
- 855 J/g for ethyl alcohol at 78 °C
- 1086 J/g for methyl alcohol at 65 °C
- 2258 J/g for water at 100 °C

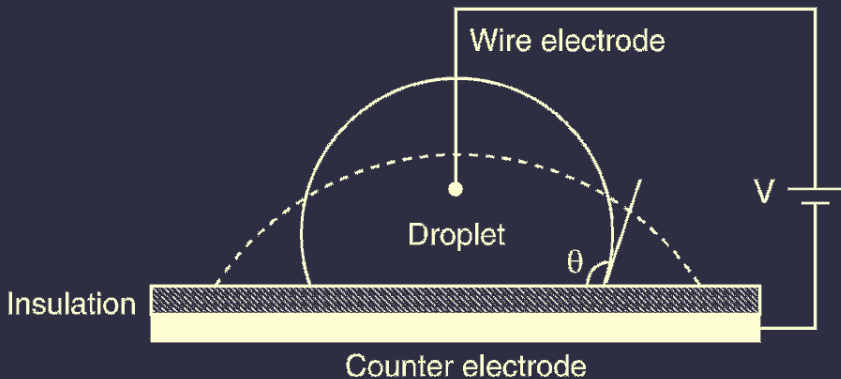
# Heat pipe



## Heat pipe thermal cycle

- 1) Working fluid evaporates to vapour absorbing thermal energy.
- 2) Vapour migrates along cavity to lower temperature end.
- 3) Vapour condenses back to fluid and is absorbed by the wick, releasing thermal energy
- 4) Working fluid flows back to higher temperature end.

# Electrowetting



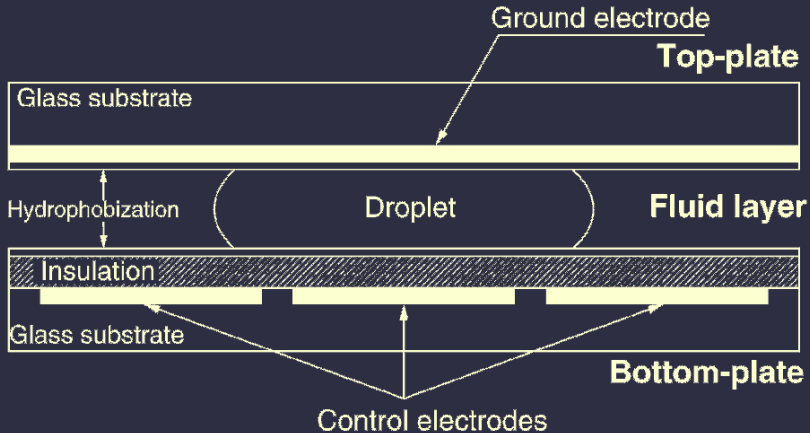
Credit to M. G. Pollack for image.

# Electrowetting

$$\gamma_{SL} = \gamma_{SL}^0 - \frac{\epsilon V^2}{2 \cdot d}$$

- $\gamma_{SL}$ : Solid-liquid interfacial tension
- $V$  applied voltage
- $\gamma_{SL}^0$ : Solid-liquid interfacial tension at  $V = 0$
- $\epsilon$ : Dielectric constant for insulating film
- $d$ : thickness of insulating film

# Electrowetting microactuator



Credit to M. G. Pollack for image.



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# Electrical and thermal fields

$$\vec{J}_Q = + \kappa \vec{G}$$
$$\vec{J}_e = \delta \vec{E}$$

- $\vec{J}_Q$ : Heat flow
- $\kappa$ : Thermal conductivity
- $\vec{G}$ : Temperature gradient
- $\vec{J}_e$ : Electrical current
- $\delta$ : Electrical conductivity
- $\vec{E}$ : Electric potential gradient

Credit to Prof. Grayson for his notes on this topic.

# Thermoelectric interdependence

In the same electric field, hot electrons travel faster than cold electrons inducing heat flow

$$\vec{J}_Q = D\vec{E}$$

Charge flows faster from hot regions to cold regions

$$\vec{J}_e = C\vec{G}$$

## Thermoelectric effects

$$\begin{aligned}\vec{J}_e &= \delta \vec{E} + C \vec{G} \\ \vec{J}_Q &= \kappa \vec{G} + D \vec{E} \\ D &= CT\end{aligned}$$

where  $T$  is temperature.

# Thermoelectric devices

Solve for  $\vec{E}$  and  $\vec{J}_Q$

$$\vec{E} = \vec{J}_e / \delta - S \vec{G}$$

$$\vec{J}_Q = \pi \vec{J}_e + (\kappa - \delta S \pi) \vec{G}$$

$$\pi = S T$$

# Peltier effect

$$\vec{J}_Q = \pi \vec{J}_e \Rightarrow I_Q = \pi I_e$$

where  $I_q$  is the total heat current and  $I_e$  is the total electrical current.  
Within a piece of metal

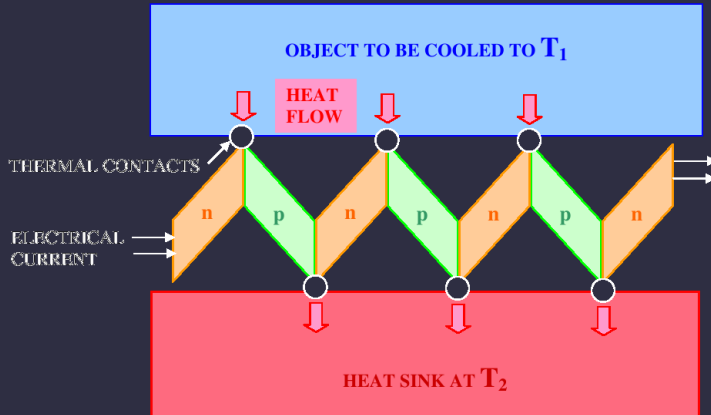
$$I_Q^{in} = I_Q^{out} = \pi I_e$$

However, at junction

$$I_Q^{in} - I_Q^{out} = (\pi_A - \pi_B) I_e$$

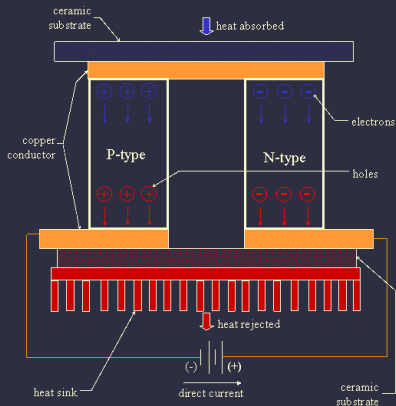
Thus heat can be transported from one junction to another via charge carriers.

# Peltier heat pumps



# Peltier heat pumps

Schematic of a Thermoelectric Cooler



Credit for image to TE Technology, Inc.



# Stacked Peltier



Credit for image to TE Technology, Inc.